



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Adrien Dromard et al.

Application No.: 10/583,417

Filing Date: April 26, 2007

Title: HIGHLY-STRUCTURED SILICA
HAVING A LOW WATER UPTAKE,
PREPARATION METHOD THEREOF
AND USES OF THE SAME

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)
) Group Art Unit: 1793

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) Examiner: Serena L. Hanor

)
) Confirmation No.: 3689

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The following extension of time is requested to: respond to Official Action dated February 17, 2009 for

Three Months to May 17, 2009

☒ \$ 1110

☐ \$ 555

☒ Charge \$ 1110 to credit card. Form PTO-2038 is attached.

The Director is hereby authorized to charge any appropriate fees under 37 C.F.R. §§1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BUCHANAN INGERSOLL & ROONEY PC

Date: August 17, 2009

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